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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/078,831	02/18/2002	Sanh Dang Tang	MIO 0018 V2/96-1138.03	8095
7590 05/03/2004			EXAMINER	
Killworth, Gottman, Hagan & Schaeff, L.L.P.			ESTRADA, MICHELLE	
One Dayton Centre, Suite 500 Dayton, OH 45402-2023			ART UNIT	PAPER NUMBER
			ARTONIT	TAFER NOMBER
			2823	

DATE MAILED: 05/03/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		Applicati n No.	Applicant(s)			
Office Action Summary		10/078,831	TANG, SANH DANG			
		Examiner	Art Unit			
		Michelle Estrada	2823			
 Period for	The MAILING DATE of this communication Reply	appears on the cover sheet with the o	correspondence address			
THE M - Extens after S - If the p - If NO p - Failure Any re	RTENED STATUTORY PERIOD FOR RELATIONS DATE OF THIS COMMUNICATION Signs of time may be available under the provisions of 37 CFR IX (6) MONTHS from the mailing date of this communication. Seriod for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory per to reply within the set or extended period for reply will, by staply received by the Office later than three months after the main patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a reply be ting reply within the statutory minimum of thirty (30) day iod will apply and will expire SIX (6) MONTHS from atute, cause the application to become ABANDONE	mely filed ys will be considered timely. the mailing date of this communication. ED (35 U.S.C. § 133).			
Status						
1)⊠ !	Responsive to communication(s) filed on 10	<u>December 2003</u> .				
2a)🖾 -	This action is FINAL . 2b) ☐ T	his action is non-final.				
3)□ \$	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Dispositio	on of Claims	·				
5) (6) (7) (Claim(s) 1-9 is/are pending in the application of the above claim(s) is/are without claim(s) is/are allowed. Claim(s) 1-9 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction an	drawn from consideration.				
Application	on Papers					
9)[] T	he specification is objected to by the Exam	iner.				
10)∐ T	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.					
,	Applicant may not request that any objection to	the drawing(s) be held in abeyance. Se	e 37 CFR 1.85(a).			
	Replacement drawing sheet(s) including the cor he oath or declaration is objected to by the		•			
Priority u	nder 35 U.S.C. § 119					
12)	Acknowledgment is made of a claim for fore All b) Some * c) None of: 1. Certified copies of the priority documents. Certified copies of the priority documents. Copies of the certified copies of the papelication from the International Burse the attached detailed Office action for a	ents have been received. ents have been received in Application of the contraction of the	ion No ed in this National Stage			
Attachment(
	of References Cited (PTO-892)	4) Interview Summary Paper No(s)/Mail D	•			
3) 🔲 Inform	of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449 or PTO/SB/No(s)/Mail Date	-: DAY 11 - 41 - 4 - 4	Patent Application (PTO-152)			

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DETAILED ACTION

The finality of the Office Action mailed 12/03/03 has been withdrawn in view of the letter filed 12/10/03.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-6, 8 and 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Blalock (5,320,981) and Wu (5,940,731).

Blalock discloses a substrate (12); a layer of dielectric material (14) formed on at least a portion of said substrate; a layer of conductive material (10) formed within said layer of dielectric material; a layer of etch resistant material such as a photoresist; at least a portion of said layer of dielectric material and said layer of etch resistant material each having openings therein defining a via, said via exposing at least a portion of said layer of conductive material (Col. 4, lines 30-35 and Fig. 2); wherein said layer of conductive material contacts at least a portion of said substrate.

Wu does not disclose a layer of hard mask material formed on at least a portion of said layer of dielectric material; said layer of dielectric material including a pair of shoulders having hard mask material thereon, and said layer of hard mask material having a pair of facets.

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Blalock discloses a dielectric layer (14) having a via; a hard mask layer (28) formed on at least a portion of said layer of dielectric material; said layer of dielectric material including a pair of shoulders (34) having hard mask material thereon of polycrystalline silicon, and said layer of hard mask material having a pair of facets (See Fig. 6); and an interconnect material (72) in said via.

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Blalock and Wu to enable formation of the interconnect structure.

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Blalock (5,320,981) and Wu (5,940,731) as applied to claims 1-6, 8 and 9 above, and further in view of Linn et al. (5,547,896)

The combination of Blalock and Wu does not disclose that the hard mask material comprises a titanium-tungsten alloy.

Linn et al. disclose titanium-tungsten alloy as a suitable material for a hard mask layer (Col. 3, line 9).

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Blalock, Wu and Linn et al. to enable formation of the hard mask layer.

Response to Arguments

Applicant argues the Examiner has provided no motivation or reasoning as to how one skilled in the art would modify the references to arrive at the claimed

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semiconductor device precursor. However, motivation has been provided in the Office Action mailed 7/30/03, it would have been within the scope of one of ordinary skill in the art to combine the teachings of Blalock and Wu to enable formation of the interconnect structure.

In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Applicant argues that Wu does not teach a hard mask layer which is formed by a single deposition of hard mask material as taught in the present invention. However, the method of forming the device is not germane to the issue of patentability of the device itself. Therefore, this limitation has not been given patentable weight.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

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the advisory action. In no event, however, will the statutory period for reply expire later

than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Michelle Estrada whose telephone number is 571-272-

1858. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone numbers

for the organization where this application or proceeding is assigned are 703-308-7722

for regular communications and 703-308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is 571-272-

2800.

George Fourson
Primary Examiner

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MEstrada

April 20, 2004